POISONING EFFECT OF CARBON MONOXIDE ON THE DESORPTION PROCESS OF HYDROGEN FROM PALLADIUM

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The desorption of H_2 from clean and CO-poisoned Pd wires was studied by a temperature programmed desorption technique. Poisoning effect of CO on H_2 desorption process can be accounted for in terms of blockage of the surface sites for the recombination of H atoms.

Десорбция H₂ с чистой палладиевой проволоки и, отравленной СО, была исследована методом температурно-программированной десорбции. Отравляющий эффект СО на процесс десорбции H₂ вызван, вероятно, блокированием поверхностных центров, на которых происходит рекомбинация атомов водорода.

It is well known that at low temperatures (< 100 °C) the absorption rates of H₂ by Pd are very sensitive to the presence of impurities on the surface /1/. These results suggest that the steps on the surface, e.g. dissociation of H₂, may be responsible for the absorption process. It is expected that a similar situation exists in the case of the desorption process of H₂. However, few data from this point of view have been reported up to the present /2, 3/. CO is one of the best known inhibitors for catalytic hydrogenation reactions. Conrad et al. /4/, studying the coadsorption of H₂ and CO on Pd, have found that CO may displace preadsorbed H₂ completely from the surface, whereas no displacement of adsorbed CO by H₂ takes place. The purpose of this work was to clarify the effect of CO on the desorption process of H₂ from the Pd-H system by a temperature programmed desorption technique (TPD).

EXPERIMENTAL

Experiments were performed in an UHV system (base pressure 10^{-9} Torr). A Pd wire (>99.9% pure) 0.02 cm in diameter and 50 cm in length was used. The specimen was welded to metal leads in the reaction cell and connected to a bridge circuit. Cleaning and activation of the Pd surface were carried out by the following oxidation-reduction cycles: (1) first outgassed at 800 °C in vacuum for several hours, (2) heated in O₂ (1 Torr) at 200 °C for 1 h, (3) pumped, then H₂ (1 Torr) for 1 h at 300 °C, and (4) pumped to 10⁻⁹ Torr. It has been confirmed by different investigators that the electrical resistance in the α -phase of Pd-H system is proportional to the H concentration /5, 6/. Therefore, the specimen was exposed to H₂ (1 Torr) in a limited time at room temperature and then the amount of dissolved H was determined by measuring the resistance change (accuracy $\pm 10^{-4} \Omega$). All the experiments were carried out using specimens in the range of α -phase (atomic ratio, H/Pd = 0.0006 - 0.005). Following the absorption, the cell was rapidly cooled to -196 °C and pumped out and than TPD was commenced with a heating rate of 0.2 °C/sec. The temperature of the specimen was measured by a thermocouple which was in contact with the specimen. The changes in the partial pressuredue to desorbing gases were recorded with a B-A gauge and a mass filter simultaneously. Surface poisoning was made by exposure of the H containing specimens to CO at different pressures $(10^{-3}-10^{-4} \text{ Torr})$ at room temperature. The gases (H2, O2 and CO) of high purity were obtained from the Takachiho Co. and used without further purification.

RESULTS AND DISCUSSION

Desorption of H_2 from clean surfaces. Figure 1 shows typical TPD curves for the specimens with H/Pd = 0.0006-0.005. The desorption always commenced at the same temperature, about -180 °C. Only a single peak can be detected and the position of peak maximum shifts to lower temperatures with the increase of H content. This temperature shift and the symmetric shape of the spectra suggest that the desorption obeys second-order kinetics /7, 8/. Therefore, the data were analyzed in term of the equation

$$E_{d}/RT_{m}^{2} = (n_{o}\nu/\beta) \exp(-E_{d}/RT_{m}),$$

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where ν is the preexponential factor, E_d the activation energy of desorption, n_O initial H concentration, β heating rate and T_m the temperature at which the desorp-



Fig. 1. TPD spectra of H_2 from Pd with different H contents. H/Pd, (A) 0.005, (B) 0.004, (C) 0.0024, (D) 0.0006



Fig. 2. Plot of $ln(n_0 \cdot T_m^2)$ vs. l/T_m



Fig. 3. Effect of CO poisoning on TPD spectra of H₂ for the specimens with H/Pd = 0.0025.
(A) without poisoning; dose pressure of CO, (B) 3 x 10⁻⁴ Torr, (C) 1.5 x 10⁻³ Torr. Curves (D) and (E) show the desorption of CO from specimens (B) and (C)

tion rate is maximum. Figure 2 shows that the desorption is well represented by second-order kinetics with an E_d of 15.5 kcal. An E_d value of 11.5 kcal was found by Auer and Grabke /6/, using thin foils of the α -phase. It was suggested by them that this value is equal to the sum of the heat of dissolution of H_2 (4.7 kcal) and the activation energy of absorption (6.8 kcal). Bucur et al. /9, 10/ also obtained a second-order rate law and E_d of 20.5 kcal on thin films under isothermal desorption conditions. These results suggest that the rate-controlling step of the desorption undoubtedly occurs at the surface. The discrepancy of E_d is difficult to explain but it may presumably result from the different type of specimens and the different methods of investigation used.

Desorption of H_2 from CO-poisoned surfaces. Figure 3 shows TPD spectra obtained from CO-poisoned specimens (H/Pd = 0.0025). It is seen that the initiation temperatures of H_2 desorption (T_d) are shifted to 0 °C with increase of CO dose pressure, whereas T_m (about 70 °C) is almost unaffected. A relation between T_d and the dose pressure of CO is given in Fig. 4. In Fig. 3, CO desorption patterns are similar to those found by Stephan et al. /11/ and these peaks can be attributed to chemisorbed CO. It is clear that the rates of H₂ desorption rapidly increase with removal of prechemisorbed CO, that is, the surface steps in the desorp-



Fig. 4. Change in the initiation temperature (T_d) of H_2 desorption as a function of CO dose pressure

tion process are strongly inhibited by the presence of CO. During thermal desorption, only desorption of H_2 and CO were observed and no reaction products were found. This fact is in agreement with the results of Conrad et al. /4/ observed in the case of mixed adsorbed layers on single crystal planes of Pd. Further, it was observed that T_m was independent of the amount of dissolved H in the range H/Pd = 0.0025 - 0.006. At present, we have no satisfactory explanation for the mechanism of H_2 desorption from poisoned surfaces, but observations suggest that the interaction between H and CO at the surface must be weak and the chemisorbed CO merely blocks up the available sites for H recombination.

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